



INTERNATIONAL
GEMOLOGICAL
INSTITUTE

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LABORATORY GROWN DIAMOND REPORT

July 15, 2026

IGI Report Number

LG815626797

Description

LABORATORY GROWN DIAMOND

Shape and Cutting Style

OVAL BRILLIANT

Measurements

8.58 X 6.14 X 3.79 MM

GRADING RESULTS

Carat Weight

1.27 CARAT

Color Grade

E

Clarity Grade

VVS 1

ADDITIONAL GRADING INFORMATION

Polish

EXCELLENT

Symmetry

EXCELLENT

Fluorescence

NONE

Inscription(s)

 LG815626797

Comments: As Grown - No indication of post-growth treatment.
This Laboratory Grown Diamond was created by High Pressure High Temperature (HPHT) growth process. Type II

PROPORTIONS

Slightly Thick To Thick (Faceted)

14%

43.5%

60%

61.7%

Pointed



Sample Image Used

COLOR

D

E

F

G

H

I

J

Faint

Very Light

Light

CLARITY

FL

IF

VVS¹⁻²

VS¹⁻²

SI¹⁻²

I¹⁻³

Flawless

Internally Flawless

Very Very Slightly Included

Very Slightly Included

Slightly Included

Included



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Carat Weight

1.27 CARAT

Color Grade

E

Clarity Grade

VVS 1

Depth

61.7%

Table

60%

Girdle

Slightly Thick To Thick (Faceted)

Culet

Pointed

Polish

EXCELLENT

Symmetry

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Fluorescence

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www.igi.org